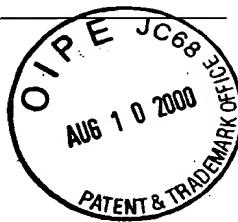


PATENT
Docket No.: M4065.0165/P165

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Garry Mercaldi et al.

Serial No.: 09/285,773



Group Art Unit: 1765

Filed: April 5, 1999

Examiner: L. Eronini

For: METHOD FOR ETCHING
DOPED POLYSILICON WITH
HIGH SELECTIVITY TO
UNDOPED POLYSILICON

Assistant Commissioner for Patents
Washington, D.C. 20231

AMENDMENT

Dear Sir:

In response to the Office Action dated June 7, 2000 (Paper No. 6), please amend the above-identified U.S. patent application as follows:

IN THE CLAIMS:

Please delete claims 8, 12 and 19-21.

Please amend the following claim:

A 1 1. (amended) A composition for selectively etching a doped substance, said composition consisting essentially of:

